

Electronic Supplementary Information

Electrode dependence in halide perovskite memories: Resistive switching behaviours

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Table S1. Comparison table of resistive switching memories employing halide perovskites with various top electrodes.

Device Structure	Type of Resistive Switching	ON/OFF ratio	Endurance (cycle)	Retention (s)	Top Electrode	Ref
Au/MAPbI ₃ /Au/SiO ₂ /Si	Unipolar	10 ⁸	1000	>10 ⁴	Au	1
Au/MAPbI ₃ /Au/Ti/SiO ₂ /Si	Unipolar	3 × 10 ⁷	100	>10 ³	Au	2
Ag/Bphen/MAPbBr ₃ /PEDOT:PSS/ITO	Unipolar	80	40	600	Ag	3
Au/CH ₃ NH ₃ PbI ₃ /Pt/Ti/SiO ₂ /Si	Bipolar	>10 ³	500	>10 ⁵	Au	4
Au/A ₃ Bi ₂ I ₉ /Pt/Ti/SiO ₂ /Si	Bipolar	>10 ⁷	400	10 ³	Au	5
Au/CH ₃ NH ₃ PbI ₃ /TiO ₂ /FTO	Bipolar	10 ³	350	>10 ⁴	Au	6
Au/Cs ₃ Sb ₂ I ₉ /ITO	Bipolar	-	500	5000	Au	7
Au/CH ₃ NH ₃ PbI _{3-x} Br _x /ITO	Bipolar	>10 ²	-	>10 ⁴	Au	8
Ti/TiO ₂ /CH ₃ NH ₃ PbCl _x I _{3-x} /Au	Bipolar	20	-	>10 ⁴	Au	9
Au/CH ₃ NH ₃ PbI ₃ /ITO/PET	Bipolar	10 ⁴	400	>10 ⁴	Au	10
Au/CsPb ₂ Br ₅ /ITO	Bipolar	~10 ²	500	10 ⁴	Au	11
Au/(ZnO)/MAPbI ₃ /ITO	Bipolar	-	300	>10 ⁴	Au	12
Au/Cs ₄ PbBr ₆ /PEDOT:PSS/ITO	Bipolar	-	100	10 ⁴	Au	13

Au/Cs _{0.06} FA _{0.78} MA _{0.16} Pb(I _{0.92} Br _{0.08}) ₃ /ITO	Bipolar	>10 ²	10 ³	10 ⁵	Au	14
Au/Cs ₃ Sb ₂ Br ₉ /Au	Bipolar	>10 ³	200	2 × 10 ⁴	Au	15
Au/Cs ₂ BiAgBr ₆ /ITO	Bipolar	10 ⁴	100	10 ³	Au	16
Ag/CH ₃ NH ₃ PbI _{3-x} Cl _x /FTO	Bipolar	-	10 ³	4 × 10 ⁴	Ag	17
Ag/AZO/(C ₄ H ₉ NH ₃) ₂ PbBr ₄ /Pt	Bipolar	10 ⁶	3 × 10 ⁴	5 × 10 ⁴	Ag	18
ITO/PMMA/CH ₃ NH ₃ PbBr ₃ :PMMA/PMMMA/Ag	Bipolar	>10 ³	-	4000	Ag	19
Ag/CH ₃ NH ₃ PbI ₃ /Pt	Bipolar	10 ⁶	10 ³	29800	Ag	20
Ag/CsPbBr ₃ /Ag	Bipolar	~10 ³	10 ³	>400	Ag	21
FTO/CH ₃ NH ₃ PbI _{3-x} Cl _x /Ag Probe	Bipolar	10 ⁶	10 ⁴	2 × 10 ³	Ag	22
Ag/(PEA) ₂ Cs ₃ PbI ₁₃ /Pt/Ti/SiO ₂ /Si	Bipolar	10 ⁹	200	2000	Ag	23
Ag/PMMA/PEA ₂ PbI ₄ /MAPbI ₃ /Pt/Ti/SiO ₂ /Si	Bipolar	>10 ⁶	2700	>10 ³	Ag	24
Ag/CsPbBr ₃ /MoO ₃ /Ag	Bipolar	>100	50	-	Ag	25
Ag/BA ₂ PbI ₄ /Pt	Bipolar	-	250	10 ³	Ag	26
Ag/CsSnBr ₃ /Pt	Bipolar	>10 ²	-	-	Ag	27
Ag/BA ₂ CsAgBiBr ₇ /Pt	Bipolar	10 ⁷	~1000	2 × 10 ⁴	Ag	28
Ag/CsSnCl ₃ /ITO	Bipolar	10 ²	10 ⁵	>10 ⁴	Ag	29
Ag/PMMA/CsSnI ₃ /Pt/Ti/SiO ₂ /Si	Bipolar	>10 ³	600	7 × 10 ³	Ag	30
Au/PMMA/CsSnI ₃ /Pt/Ti/SiO ₂ /Si		>5 × 10 ²	120	-		
Al/CsPbBr ₃ /PEDOT:PSS/ITO/PET	Bipolar	~10 ²	50	-	Al	31
Al/PMMA/CsPbCl ₃ /PMMA/ITO	Bipolar	2 × 10 ⁴	95	1 × 10 ⁴	Al	32
Al/Cs ₃ Cu ₂ I ₅ /ITO	Bipolar	~65	200	10 ⁴	Al	33
ITO/MAPbI _{3-x} Cl _x /2D perovskite/Al	Bipolar	>10 ³	10 ⁴	3 × 10 ²	Al	34
Al@MAPbI ₃ /Al	Bipolar	~10 ⁶	500	>10 ⁴	Al	35
ITO/FA-MA-Cs trication perovskite/PMMMA/Al	Bipolar	>10 ³	130	10 ⁴	Al	36
ITO/MAPbI ₃ -TiO ₂ /PMMA/Al	Bipolar	-	50	10 ³ ~10 ⁴	Al	37
Al/CsBi ₃ I ₁₀ /ITO	Bipolar	10 ³	150	10 ⁴	Al	38
Al/PCBM/Cs ₃ Sb ₂ I ₉ /PEDOT:PSS:ITO	Bipolar	~10 ⁴	100	>10 ⁴	Al	39
ITO/PEI/CH ₃ NH ₃ PbI ₃ /PEI/metal	Bipolar	20	4000	-	InGa, Al, Au	40
Pt/CsPbBr ₃ /Cu ₂ O/FTO	Bipolar	10 ³	1000	-	Pt	41

FTO/ZnO/CH ₃ NH ₃ PbI _{1-x} Bi _x I ₃ /Pt	Bipolar	10 ⁵	100	-	Pt	42
Pt/Cs ₂ AgBiBr ₆ /ITO /	Bipolar	~100	>500	>2400	Pt	43
Pt/CsSnBr ₃ /Pt	Bipolar	>10 ⁵	50	10 ⁴	Pt	44
Ni/ZnO/CsPbBr ₃ /FTO	Bipolar	>10 ⁵	100	>10 ⁴	Ni	45
FTO/CH ₃ NH ₃ PbI ₃ /W	Bipolar	>10 ²	100	-	W	46
Cu/MA ₃ Bi ₂ I ₉ /ITO	Bipolar	10 ⁴	1730	3 x 10 ⁵	Cu	47
Ag/PMMA/4wt%-RbPbI _{2.4} Cl _{0.6} @PMMA/ITO	Bipolar	>10 ³	1000	10 ⁴	Ag	48
Ag/PMMA/6wt%-RbPbI _{2.4} Cl _{0.6} @PMMA/ITO	Worm	-	-	-		
ITO/CH ₃ NH ₃ PbI ₃ /Al	Bipolar	-	-	-	Al	
ITO/CH ₃ NH ₃ PbI ₃ /Ag	WORM	-	-	-	Ag	49
ITO/CH ₃ NH ₃ PbI ₃ /Au	WORM	-	-	-	Au	
Au/FAMAPbI ₃ /ITO	WORM	40	-	10 ²	Au	50
Au/(RNH ₃) ₂ (FA) ₁ Pb ₂ Br ₇ /ITO	WORM	10 ²	-	10 ⁴	Au	51
Au/MAPbBr ₃ /ITO	WORM	10 ⁶	-	10 ⁴	Au	52
Au/CsPbBr ₃ /ITO	WORM	10 ⁴		>10 ³	Au	53
ITO/CH ₃ NH ₃ PbI ₃ :PVK/AI	WORM	>10 ³	-	-	Al	54
Al/MAPbBr ₃ :PEO/AI	WORM	10 ⁴	-	10 ⁴	Al	55
Al/(CH ₃ NH ₃) ₂ PbI ₂ (SCN) ₂ /ITO	WORM	10 ³	-	10 ⁴	Al	56
Au/PMMA/AgBi ₂ I ₇ -Cs ₃ Bi ₂ I ₉ /Pt	Multilevel	>10 ⁷	10 ³	>5 x 10 ⁴	Au	57
Au/MA ₃ Bi ₂ I ₉ /ITO	Multilevel	100	300	~10 ⁴	Au	58
Au/CsPbBr ₃ /ITO	Multilevel	10 ⁷	-	>10 ³	Au	59
Au/CsPbBr ₃ /FTO	Multilevel	~10 ⁵	1000	>10 ⁴	Au	60
Au/KCl-CH ₃ NH ₃ PbI _{3-x} Cl _x /ITO	Multilevel	-	140	>10 ³	Au	61
(ITO)/CsSnBr ₃ /Au	Multilevel	~10 ⁵	400	~10 ³	Au	62
Ag/CsPb _{1-x} Bi _x I ₃ /ITO	Multilevel	-	250	~10 ⁴	Ag	63
Ag/PMMA/[C ₆ H ₅ (CH ₂) _n NH ₃]CuBr ₄ /Pt/Ti/SiO ₂ /Si	Multilevel	~10 ⁸	2000	>10 ²	Ag	64
Pt/oxide-passivated MAPbI ₃ /PMMA/Ag	Multilevel	10 ⁶	5.7 x 10 ⁴	7.8 x 10 ⁴	Ag	65
Ag/CsPbBr ₃ /Pt	Multilevel	~10 ⁴	-	>5 x 10 ⁴	Ag	66
Ag/FAPbI ₃ /Pt	Multilevel	>10 ⁵	1200	3000	Ag	67

Ag(AgO _x)/Cs ₃ Bi ₂ I ₁₀ /FTO	Multilevel	$\sim 10^6$	250	$>10^3$ $<10^3$	Ag	68
Ag(AgO _x)/Cs ₃ Bi ₂ I ₉ /FTO	Multilevel	$>10^6$	300	1000	Ag	69
Al/CsPbCl _x Br _{3-x} , (x = 3, 1.5, 0)/ITO/PET	Multilevel	$\sim 10^3$	10 ³	$>10^3$	Al	70
Al/RbPbBr ₃ /ITO/PET	Multilevel	10 ³	1000	$\sim 10^4$	Al	71
NiO/(C ₄ H ₉ NH ₃) ₂ PbBr ₄ /ZnO/FTO	Multilevel	-	-	-	NiO	72
Pt/Cs ₂ AgBiBr ₆ /ITO	Multilevel	500	-	1200	Pt	73

*MA = CH₃NH₃, FA= HC(NH₂)₂

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